

TITLE OF THE INVENTION: PROCESSING FACILITY

Abstract

5 A processing facility is disclosed in which a container side contact surface and a support side contact surface are in contact with each other and a supply hole or a discharge hole, and a communicating hole are allowed to communicate with each other when a container is supported by a container support, and in which the container side contact surface is formed to be flat at least in a periphery of the communicating hole, and the support side contact
10 surface is formed to have a shape that is gradually lower as a distance increases from the supply hole or the discharge hole.

Fig. 7